• • • • • • • • • • • • • • • • • • •	Search Text	DB	Time stamp
1 2	(temporary) same (back near side near5 etch\$3)	USPAT. US-PGPUB	2002/11/05 14:44
2 10867	(field near oxide or "FOX") same etch\$3	USPAT: US-PGPUB: EPO: JPO: DERWENT: IBM TDB	2002/11/05 15:05
3 11	((field near oxide or "FOX") same etch\$3) same (back near side near etch\$3)	USPAT: US-PGPUB: EPO: JPO: DERWENT: IBM TDB	2002/11/05 14:47
4 0	(((field near oxide or "FOX") same etch\$3) same (back near side near etch\$3)) same protective	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/11/05 14:48
5 11	(((field near oxide or "FOX") same etch\$3) same (back near side near etch\$3)) and (protect\$3 near film or layer)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/05 14:49
6 509	((field near oxide or "FOX") same etch\$3) and (protective near layer)	USPAT US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/05 15:06
7 145	(((field near oxide or "FOX") same etch\$3) and (protective near layer)) and (back near3 etch\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/05 15:26
8 5	((((field near oxide or "FOX") same etch\$3) and (protective near layer)) and (back near3 etch\$3)) and ((fluid near eject\$3) or (print near head))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/11/05 15:08
9 130	((((field near oxide or "FOX") same etch\$3) and (protective near layer)) and (back near3 etch\$3)) and (mask\$3 or capp\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/11/05 15:35
10 82	(((((field near oxide or "FOX") same etch\$3) and (protective near layer)) and (back near3 etch\$3)) and (mask\$3 or capp\$3)) and (hole or oppen\$3 or groove or (through near hole))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/05 15:56
11 4722929	open\$3 or slot or hole or through near hole	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/05 16:05
12 84836	(open\$3 or slot or hole or through near hole) and (ink or fluid near eject\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/05 16:06
13 41396	(open\$3 or slot or hole or through near hole) same (ink or fluid near eject\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/05 16:17
14 30907	((open\$3 or slot or hole or through near hole) same (ink or fluid near eject\$3)) and (fill\$3 same trench or open\$3)	USPAT: US-PGPUB: EPO: JPO: DERWENT: IBM_TDB_	2002/11/05 16:11

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15	17	(((open\$3 or slot or hole or through near hole) same (ink or fluid near eject\$3)) and (fill\$3 same trench or open\$3)) and (back near side near etch\$3)	USPAT: US-PGPUB: EPO; JPO: DERWENT:	2002/11/05 16:40
16	2335	plug same (back near3 etch\$3)	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2002/11/05 16:41
17	3949	(plug or protect\$3) same (back near3 etch\$3)	IBM_TDB USPAT: US-PGPUB: EPO; JPO: DERWENT; IBM_TDB	2002/11/05 16 42
18	1904	((plug or protect\$3) same (back near3 etch\$3)) same (slot or open\$3 or hole)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/11/05 16.43
19	1248	(((plug or protect\$3) same (back near3 etch\$3)) same (slot or open\$3 or hole)) and @pd<20010622	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/05 16:44
20	59	((((plug or protect\$3) same (back near3 etch\$3)) same (slot or open\$3 or hole)) and @pd<20010622) and (eject\$3 or print\$3)	USPAT;	2002/11/05 16:45
-	0	(hole near5 plug) same (back near side near5 etch\$3)	USPAT; US-PGPUB	2002/11/05 14:39
-	938	(back near side near5 etch\$3)	USPAT; US-PGPUB	2002/11/04 17:09
-	44	( (back near side near5 etch\$3)) and (hole same (front near surface))	USPAT; US-PGPUB	2002/11/04 17:11
-	25	(( (back near side near5 etch\$3)) and (hole same (front near surface))) and @pd<20010622	USPAT; US-PGPUB	2002/11/04 17:12
-	2		USPAT; US-PGPUB	2002/11/05 08:35
-	2	(("5734399") or ("5463413")).PN.	USPAT; US-PGPUB	2002/11/05 08:37
-	1892	plug same (back near3 etch\$3)	USPAT; US-PGPUB	2002/11/05 08:38
-	2335	plug same (back near3 etch\$3)	USPAT; US-PGPUB: EPO; JPO; DERWENT; IBM_TDB	2002/11/05 09:17
-	2	(plug same (back near3 etch\$3)) and ((print near head) or (fluid near ejection))	USPAT: US-PGPUB: EPO: JPO: DERWENT: IBM TDB	2002/11/05 08:40
-	832	(plug same (back near3 etch\$3)) and trench	USPAT; US-PGPUB; EPO: JPO: DERWENT; IBM TDB	2002/11/05 08:45
-	498	((plug same (back near3 etch\$3)) and trench) and @pd<20010622	USPAT; US-PGPUB; EPO: JPO; DERWENT, IBM TDB	2002/11/05 09:45
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-	139	(((plug same (back near3 etch\$3)) and trench) and @pd<20010622) and (remov\$3 near5 plug)	USPAT; US-PGPUB; EPO: JPO; DERWENT;	2002/11/05 08:47
-	31	(((plug same (back near3 etch\$3)) and trench) and @pd<20010622) and (eject\$3 or print\$3)	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/05 10:00
_	150958	(hole or open\$3) same plug	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/11/05 10:02
-	44	((hole or open\$3) same plug) and (etch\$3 near3 (back near side))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/05 11:29
-	33079	(slot or through near hole) same (die or wafer)	USPAT; US-PGPUB; EPO; JPO; DERWENT IBM_TDB	2002/11/05 11:32
-	22	((slot or through near hole) same (die or wafer)) same ((back near side) near3 etch\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/11/05 12:07
-		(plug same (back near3 etch\$3)) and ((slot or through near hole) same (die or wafer))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/05 12:07

L Number 1	Hits 2	Search Text (("5734399") or ("0463413")).PN.	DB USPAT:	Time stamp 2002/11/05 08:35
4	2	(("5734399") or ("5463413")).PN.	US-PGPUB USPAT: US-PGPUB	2002/11/05 08:37
5	1892	plug same (back near3 etch\$3)	USPAT: US-PGPUB	2002/11/05 08:38
6	2335	plug same (back near3 etch\$3)	USPAT: US-PGPUB: EPO: JPO: DERWENT.	2002/11/05 09:17
7	2	(plug same (back near3 etch\$3)) and ((print near head) or (fluid near ejection))	IBM_TDB USPAT: US-PGPUB; EPO; JPO: DERWENT;	2002/11/05 08:40
8	832	(plug same (back near3 etch\$3)) and trench	IBM_TDB USPAT: US-PGPUB; EPO: JPO; DERWENT;	2002/11/05 08:45
9	498	((plug same (back near3 etch\$3)) and trench) and @pd<20010622	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2002/11/05 09:45
10	139	(((plug same (back near3 etch\$3)) and trench) and @pd<20010622) and (remov\$3 near5 plug)	IBM_TDB USPAT; US-PGPUB; EPO: JPO; DERWENT;	2002/11/05 08:47
11	31	(((plug same (back near3 etch\$3)) and trench) and @pd<20010622) and (eject\$3 or print\$3)	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2002/11/05 10:00
12	150958	(hole or open\$3) same plug	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/05 10:02
13	44	((hole or open\$3) same plug) and (etch\$3 near3 (back near side))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/11/05 11:29
14	33079	(slot or through near hole) same (die or wafer)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/11/05 11:32
15	22	((slot or through near hole) same (die or wafer)) same ((back near side) near3 etch\$3)	USPAT; US-PGPUB; EPO: JPO; DERWENT; IBM TDB	2002/11/05 12:07
16	44	(plug same (back near3 etch\$3)) and ((slot or through near hole) same (die or wafer))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/05 12:07
-	0	(hole near5 plug) same (back near side near5 etch\$3)	USPAT; US-PGPUB	2002/11/05 08:33
-	938	(back near side near5 etch\$3)	USPAT; US-PGPUB	2002/11/04 17:09
- 	44 = = = = = = = = = = = = = = = = = =	( (back near side near5 etch\$3)) and (hole same (front near surface))	USPAT: US-PGPUB	2002/11/04 17:11
Search History	/ 11/5/02	12:16:35 PM Page 1		

25 (( (back near side near5 etch\$3)) and (hole same (front near surface))) and @pd<20010622

USPAT US-PGPUB 2002/11/04 17:12